

Semiconductor Device Modelling and Simulation
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Lecture - 38
Semiclassical Transport (Continued)

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The slide features a blue header with the text "L38 SCATTERING AND MOBILITY" flanked by the IIT Kharagpur logo on the left and a circular icon on the right. Below the header, a bullet point reads "Scattering and Mobility." followed by handwritten red notes: $\vec{v} = \frac{e\tau}{m^*} \vec{E}$ and $S(k, k')$. A video inset in the bottom right corner shows Prof. Vivek Dixit, a man with glasses wearing a light blue shirt, speaking. The bottom of the slide has a purple and blue geometric design with the text "SEMICONDUCTOR DEVICE MODELING AND SIMULATION".

Hello, welcome to lecture number 38. Today we will discuss about the scattering, further discussion about the scattering and mobility. So, in previous class we have learned that due to scattering the distribution function actually changes. And if the electric field is in let us say Z direction, then distribution function also changes in Z direction so only k z component changes. And from that we can drive the expression for current energy density.

And we found out that we can define one parameter called mobility which is basically e then τ average divided by m . So, now we will discuss further about the mobility and there we assumed that S is the scattering between k to k prime. So, how do we calculate this scattering and how do we calculate these mobilities? So, that we will discuss in today's lecture.

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$\begin{matrix} \rightarrow \\ \rightarrow \\ \rightarrow \\ \rightarrow \end{matrix}$


$\rightarrow$ elastic scattering
 Δp small
 $p \approx 0$

$\rightarrow$ inelastic
 $\rightarrow$

$T_e = T_v$
 $\frac{1}{T_e} \approx 0$
 $T_v \rightarrow \infty$

$\rightarrow$ elastic or no interaction
 $p \approx 0$

$T_e > T_v$

the momentum. So, the momentum relaxation time is the time taken to randomize the momentum. So, this momentum will take more time to randomize. So, that the momentum net momentum is zero so that time is τ_M . So, that is called momentum relaxation time.

Now this τ_M is more than this τ_f because there are processes which have a small deflection. If there are some isotropic processes so isotropic is basically with equal probability of deflection in all the directions. So, for such scenario τ_M will be same as τ_f for isotropic scattering then there is a energy relaxation time. So, this is basically a time so the $1/\tau$ should be σ_S times ΔE by E .

This is a time at which these electrons they lose their energy and T_E becomes a T_c carrier becomes lattice temperature. Now if there are process which are elastic so in elastic scattering there is no loss of energy so $k = k'$. So, for such processes the ΔE will be 0 so for them τ_E will be $1/\tau_E$ will be 0 that means τ_E will be infinite for elastic processes. For inelastic processes there will be some τ_E so that means this τ_E will be actually more than the τ_f and τ_M .

So, these are the different times that you may encounter in literature regarding the semiconductor. So, there is relaxation time, there is a momentum relaxation time, this energy relaxation time. So, in summary relaxation time is basically average time between two collisions, momentum relaxation time is the time taken by these carriers to randomize the momentum and energy relaxation time is a time taken by the carriers to get to the temperature of lattice. So, your carrier temperature become lattice temperature that time is energy relaxation time.

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can be expressed as a block waves. So, let us write the expression for the block wave. So, this is ψ_{initial} which is E to the power $i \cdot p \cdot r$ by H bar times u as a function of position for vector k or it can also be written as then of course some normalization vector 1 over the volume.

Which can also written as 1 over volume times E to the power $i \cdot k \cdot r$ times u_k . Now if you remember this solution for periodic wave inside the periodic potential so the travelling wave is modified by the periodic potential of the crystal. So, E to the power $i \cdot k \cdot r$ is a plane wave equation for a plane wave and that is modifier the periodic potential with same periodicity as the crystal.

So, this is ψ_i there is the scattered particle ψ_f will be again one over this normalized to volume times u^2 to power $i \cdot k' \cdot r$ times $u_{k'}$ function of r . And then this H is defined as $\psi_f^* \times \psi_i \times u$, u is the scattering potential. So, this is the scattering potential of the scattering centre. So, it could be four on impurity ionized impurity defect so on and this is the potential. So, this potential how does it arise? So, we can consider let us say phonon.

So, phonon is basically kind of vibration of these lattice atoms. So, at $T = 0$ they are fixed at their position and if you go back to some chemistry those things there are two types of potentials. One is due to the attraction others is due to the repulsion between the carrier. So, these carriers are attracted and these nucleus are repelled. So, this energy will be something like this. It will lower energy attraction force and then there is a energy something like this due to the repulsion which increases energy.

And the overall energy is basically something like this. This is the overall energy versus position r . Now there is a point of minimum energy that we call r_0 . So, these are typical the distance between these two atoms, there is a minimum energy. Now this energy can be expressed as this potential u this will change if you change this position r . So, what is happening? At high temperature this lattice atoms are vibrating.

So, this u potential as a function of r , so let us say there is some change. This is $r_0 + \Delta r$ small change is there. We can write it as $u(r_0) + \frac{du}{dr} \Delta r + \frac{1}{2} \frac{d^2u}{dr^2} \Delta r^2$ and so on. Now if this Δr is small so then this change in potential can be written as in terms of this higher order terms. Now you notice this is the minima so the $\frac{du}{dr}$ at r_0 is zero. So, the potential that is changing will be due to this term.

So, the scattering potential potentially $\frac{1}{2} \frac{d^2u}{dr^2} \Delta r^2$ so that will be the scattering potential. Now in terms of discovering potential we can write the force on these atoms. So, force is equal to $-L$ times the position double derivative will be equal to the force and force is derivative of this energy. So, that will be $-\frac{d}{dr} u$ or $-\Delta u$ you can say and that will be Δr times this term which we can write as a constant.

So, this will be basically this equation will give you the phonon characteristic. This elastic wave will have certain energy and by solving this equation you can get their phonon characteristic. So, you can get $E-k$ diagram very similar to we got for the carriers. And if you have $E-k$ diagram so E is here $\hbar \omega$ so this energy of this phonons. This phonon interacts with these carriers to scatter them.

So, now is the final energy E' which is equal to $E + \Delta E$. Now this ΔE is zero for static scattering potential and ΔE is $\pm \hbar \omega$ or scattering due to phonons because phonon will not have energy $\hbar \omega$. So, this will have plus sign if we are absorbing a phonon and it will have minus sign if we are releasing a phonon.

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FERMI'S GOLDEN RULE



$$S(\vec{p} \rightarrow \vec{p}') = \frac{2\pi}{\hbar} |H_{\vec{p}'\vec{p}}|^2 \delta(E' - E \mp \Delta E)$$

$$H_{\vec{p}'\vec{p}} = \int_{-\infty}^{\infty} \psi_f^* U_{sa}(\vec{r}) \psi_i d\vec{r}$$

$E' = E \pm \Delta E$
 $\Delta E = 0$ for a static scattering potential
 $\Delta E = \pm \hbar \omega$ for an oscillating scattering potential $U_{sa} e^{i\omega t}$

Ionized impurity

$U = -\frac{q^2}{4\pi\epsilon_0 r}$

$F(u) = \int_{-\infty}^{\infty} f(u) e^{i u x} du$

$S = \frac{1}{2}$

$H_{\vec{p}'\vec{p}} = \int_{-\infty}^{\infty} \frac{1}{\sqrt{n}} e^{-i\vec{r}\cdot\vec{r}} u_p(r) U(r) \frac{1}{\sqrt{n}} e^{i\vec{r}\cdot\vec{r}} u_p(r) dr$

$= \frac{1}{n} \int_{-\infty}^{\infty} e^{i(\vec{p}' - \vec{p})\cdot\vec{r}} U(r) dr \times \int_{-\infty}^{\infty} u_p(r) u_p(r) dr$

$= \frac{1}{n} U_F(\vec{p}' - \vec{p})$

$\vec{r} = \vec{p}' - \vec{p}$



SEMICONDUCTOR DEVICE MODELING AND SIMULATION

Then let us say we consider one scenario where let us say some let us say we consider ionized impurity. Ionized impurity will have a steady potential so let us say there is a some donor atom here N D plus, this charge is there. So, this charge will give let us say this is a charge some charge is q here. So, this will give out some potential that will be interacting with the moving carrier.

So, the corresponding energy will be U will be - q times q so that will be - q square divided by four pi epsilon r, r is a distance. So, this is the distance between the electron and this site. Now what will happen this because this is inside a semiconductor so this will get screened and we have discussed the device length well it is divided. So, it will get screened by the device length and then we can say it is e to the power - r by L D.

So, because the; field is getting actually reduced due to this screening. In metal the screening is such that the field does not extend. But in case of semiconductor the field extend to certain length then it gradually dies down and that is due to the device length because this carrier respond but they donate a much carrier like metals so field does exist. Now due to this scattering if we integrate it to get this H factor so let us integrate this H here.

So, H p prime p is integral - integral to infinity. Now psi we have already discussed is the block wave. So, this is one over volume times e to the power i tap k dot r times u k r times scattering

field. So, that we can write it as let us say some u as a function of position times 1 over volume at a k prime dot r u k prime r then we integrate it over dr for this position. So, this will be one over this then e to the power i .

Now this is the first one is the star so there is a complex conjugate so this will come $-i$ k r . So, you will have E to the power i k prime - k dot r then U potential dr and we can take this thing outside u k r , u k r k prime r . Now this is basically the product of this periodic potentials so this we can say it is one. So, your H p prime p can be written as because this is integral over the unit cell because this is a periodicity of the unit cell.

So, we can say this is 1 over σ . Now if you look at this expression carefully it is basically the expression of Fourier transform. So, this is let us say we call it u f , u f is a Fourier transform of U and the vector here will be the frequency because if you recall that four a transform f ω = f x e to the power J ω X t x - infinity. So, this is basically F of k prime - k and that we call it vector q , q is k prime - k which is basically related to the momentum.

So, the difference of the momentum of the incident vector and the scattered vector so this from k prime to k . And since the momentum has to be conserved so some particle will be involved. So, let us say there is a phonon or some particle is there so that will take care of this momentum concerned energy also. So, this k prime - k will be the wave vector of that phonon. So, this is basically the some example is given to calculate this H prime.

Then once you have this S prime then we can get from this the S scattering rate. Now this S scattering rate is from for one particular set of combination k to k prime. Now when we sum it over for all the k primes so that σ S that will give you scattering overall scattering rate. So, here we will consider some cases where the scattering rate is given for some situations.

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SCATTERING MECHANISMS



$$\tau_f(E) = \tau_0 \left(\frac{E}{k_B T} \right)^S$$

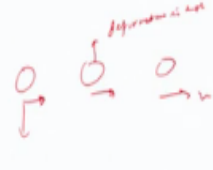
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Scattering Mechanism	Exponent S
Acoustic phonon	-1/2
Ionized impurity (weakly screened)	3/2
Ionized impurity (strongly screened)	-1/2
Neutral impurity	0
Piezoelectric	1/2



$$\langle \langle \tau_f \rangle \rangle = \tau_0 \frac{\Gamma(s + 5/2)}{\Gamma(5/2)}, \text{ where } \Gamma(p) = \int_0^\infty x^{p-1} e^{-x} dx \rightarrow \Gamma(1/2) = \sqrt{\pi}$$

*Handwritten: $\Gamma(p+1) = p\Gamma(p)$
 $\Gamma(n) = (n-1)!$*



SEMICONDUCTOR DEVICE MODELING AND SIMULATION

Now for acoustic phonon, there are two types of phonon, one is acoustic phonon one is the optical phonon. So, in acoustic phonon what happens? These atoms they oscillate in the same phase so the distance is not altered. Optical phonon are basically where they oscillate in opposite phase so there is one is going down other is going up. So, let us say this is x axis this is y axis so this will be optical phonon.

So, in this case the deformation is high in case of optical phonon deformation is high. So, generally they have high energy and then if you have this E k diagram so for this will be acoustic phonon and then this will be optical phonon, this energy $\hbar \omega$. So, for the acoustic phonon this scattering mechanism the tau is proportional to energy by k T power S where S is minus up. So, that means tau is proportional to square root of T.

Then in case of ionized impurity this is T to the power - 3 by 2 and if it is strongly screened that means there are lot of carriers then this power is minus up. And in case of neutral impurity, it does not have a charge so the mechanism is physical basically. In case of charge impurity that the scattering can be at a distance also because this electric field extend there. But in case of neutral impurity there is no electric field so the cross section of that scattering will be less here.

This is basically or not dependent on temperature. Then piezoelectric is scattering again it has exponent 1 by 2 and if you substitute this expression for tau in the previously derived equation

that we derived for we solved for the distribution function then we will get this some gamma functions there and these scattering rates are actually calculated using this average tau.

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IONIZED IMPURITY SCATTERING

potential due to an ionized impurity $= -Ze^2/4\pi\epsilon r$

It is screened by other electrons through Debye Length $\sim \epsilon k_B T / e^2 n = \epsilon V_D / en$

Scattering / transition rate from an initial state k in band n to a final state k' in band m is given by Fermi's Golden rule

$$\Gamma [n, k; m, k'] = \frac{2\pi}{\hbar} \left| \langle m, k' | V(r) | n, k \rangle \right|^2 \delta(E_{k'} - E_k \mp \hbar\omega)$$

Due to collision broadening ($\hbar/\tau$) and finite collision duration time, energy conserving delta function is only valid asymptotically (long after the collision is complete)

scattering rate for n_i number of ionized impurities per unit volume $\int_{k'} \frac{1}{k} = \sum S(k, k')$

$$\Gamma_k = \frac{n_i Z^2 e^4 m^*}{8\pi \epsilon_s^2 \hbar^3 k^3} \left[\frac{4k^2}{q_D^2 (4k^2 + q_D^2)} \right]; \quad q_D = \frac{1}{L_D}$$

SEMICONDUCTOR DEVICE MODELING AND SIMULATION

Now in case of ionized impurity scattering the potential due to ionized impurity let us say Ze^2 is the charge on the ionized impurity. So, the potential is Ze^2 by $4\epsilon r$ and if it is the screen by some length so this is the device length $\epsilon k_B T$ by $E^2 n$. So, this was e to the power $-r$ by L_D which is Debye length and then corresponding scattering rate can be obtained from the Fermi's Golden rule.

And then of course if we sum it over that means we integrate it over that $\sum S(k, k')$ then we will get the scattering rate $1/\tau$ which is given by Γ_k . So, this is the expression from the textbook. Now here two things are to be considered one is there is a collision broadening. So, collision broadening is it takes some finite amount of time for the collision to take place and that we call finite collision duration.

And this when it extends over a time so this due to this time and we can recall this rule that uncertainty principle that Δx and Δp they are related means Δx and Δp , position and momentum cannot be simultaneously determined with absolute accuracy. So, this is usually more than equal to some constant some $\hbar$ something or you can say Δx and Δk is greater than equal to one.

So, that means if the scattering is taking place so this Δk will take place over certain time or $\Delta \omega$ times Δt will be greater than equal to one, $\Delta E \hbar \Delta t$ will be so these two are the Heisenberg uncertainty principle. So, if there is a change in there is a scattering event. So, if it is over zero time then the energy cannot be determined to the greater accuracy and because there is some finite energy change there has to be some duration of the collision.

So, this is usually given by the collision broadening is given by $\hbar$ by τ . So, τ and ω are inversely proportional. So, if there is a collision duration τ then energy will have this $\hbar$ by τ variation. Now when we calculate the scattering rate for ionized impurity let us say n_i is the number of ionized impurity per volume we get this expression where L_D is basically Debye length and others have their respective meaning.

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PHONON SCATTERING

acoustic branch - neighboring atoms in a lattice oscillate in the same direction $H_i = \Xi \nabla \cdot u(r, t)$,
 optical branch - neighboring atoms oscillate in the opposite direction $H_i = D_i \cdot u(r, t)$;
 Potential felt by an electron in the conduction band is modified whenever an ion is displaced from its equilibrium, zero-temperature position. d^2U/dr^2

Lattice displacement as a function of position and time.

$$u(r, t) = \sum_q \left(\frac{\hbar}{2\rho\Omega\omega_q} \right)^{1/2} \underline{e}_q (a_q + a_q^\dagger) e^{iq \cdot r}$$

$q = k' - k$ is the phonon wave vector
 ρ is the material density
 $\hbar\omega_q$ is the phonon energy
 $\underline{e}_q$ is the unit polarization vector
 $a_q^\dagger$ and a_q are the phonon creation and annihilation operators

SEMICONDUCTOR DEVICE MODELING AND SIMULATION

Now in case of phonon scattering as we already discussed there are two possibilities. One is acoustic phonon, there is optical phonon. So, in case of optical phonon the $\hbar$ factor that is a energy is basically the potential is given by the some deflection potential times the position because these atoms are oscillating in the same phase. But in case of a acoustic branch the unit cell is actually changing. So, this is basically related to the ∇U the gradient of this position vector.

This position vector is basically the position of this lattice atoms. So, there is a deflection potential d , d times $\text{del } U$. So, that will give you the H for the acoustic branch and this we have already discussed that the potential felt by electron in the conduction band due to this ion displacement from the equilibrium that is $\text{del } U$ by $\text{del } r$ square because $d U$ by dr is 0 at that point. So, this energy has to be $d^2 U$ by dr square.

Now the lattice displacement as a function of position and time can be solved for the phonon. So, k prime - k is a phonon wave vector so where k is the wave vector of the incident particle, k prime is the wave vector of the scattered particle. And here ρ is the material density and $\hbar \omega$ is the phonon energy so where ω of q is the wave vector. So, ω of q is the corresponding frequency for the wave vector q and e is the unit vector.

These are the phonon creation Annihilation operators. So, from this U we can calculate the H and the scattering rates.

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ACOUSTIC PHONON SCATTERING



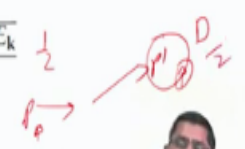
$$S(k, k') = \frac{\pi \Xi_d^2 k_B T_L}{\hbar c_L \Omega} \frac{k}{q E_k} \delta\left(\frac{q}{2k} \pm \cos \theta'\right)$$

T_L is the lattice temperature
 c_L is the material elastic constant
 θ' is the polar angle between k and q

total scattering rate out of state k for a parabolic band structure, and in the elastic and equipartition approximation

$$\frac{1}{\tau} W(k) = \frac{2\pi \Xi_d^2 k_B T_L}{\hbar c_L} N(E_k)$$

$$N(E_k) = \frac{(2m^*)^{3/2} \sqrt{E_k}}{4\pi^2 \hbar^3}$$





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So, scattering rate the important point that we should pay attention here is that this is proportional to the lattice temperature. The scattering rate divided by $1/E_k$ so E_k is energy and then total scattering rate will be $1/\tau$. So, if you see here this is proportional to T times

the density of states. You can see one more thing here because we are scattering these phonons from a P to P prime.

So, for it to be scattered to P prime the density of a state here plays a role so it is proportional to the density of a state. So, this $n(E_k)$ is the density of a state for this k vector so that is $2m^3 \times \frac{4\pi^2}{h^3} \times \frac{1}{2} \times E_k$ and there is a factor of 2 is there half. Because this P will scatter let us say this electron has spin up so this P prime will also have a spin up. So, if you consider the density of a state with a spin up then it will be D by 2 actually.

So, that is why this extra one by two factor is there because normally E_k is $1 \times 2 \pi^2 \hbar^3 q$.

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OPTICAL PHONON SCATTERING



$$S(k, k') = \frac{\pi D_{ij}^2 Z_j}{\rho \omega_{ij} \Omega} \left[n(\omega_{ij}) + \frac{1}{2} \mp \frac{1}{2} \right] \delta(E_{k'} - E_k \mp \hbar \omega_{ij} + \Delta E_{ji})$$

In Silicon
 $Z_j = 4$ for f-process
 1 for g-process

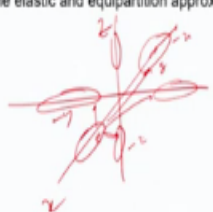
D_{ij} is the intervalley deformation potential
 Z_j is the total number of available final valleys for the carrier to scatter into
 $\hbar \omega_{ij}$ is the energy of the intervalley optical phonons involved in the scattering process
 ΔE_{ji} is the potential energy difference between the bottom of valley j and the bottom of valley i

total scattering rate out of state k for a parabolic band structure, and in the elastic and equipartition approximation

$$W(k) = \frac{\pi D_{ij}^2 Z_j}{\rho \omega_{ij}} \left[n(\omega_{ij}) + \frac{1}{2} \mp \frac{1}{2} \right] N(E_k \pm \hbar \omega_{ij} - \Delta E_{ji})$$

Phonon occupancy factor

$$n(\omega_{ij}) = \frac{1}{e^{\hbar \omega_{ij} / k_B T} - 1}$$



SEMICONDUCTOR DEVICE MODELING AND SIMULATION

And similarly for optical phonon scattering here we have different intervalley deformation potential. Let us say D_{ij} and Z_j is the total number of available final values. So, for example let us consider silicon here. So, if you remember silicon let us say this is x axis this is y axis this is z axis and the values in case of silicon, they are along this at the x there are x values. So, this is basically your x here so in the x direction, there is a y direction and there is a valley in z direction.

So, the electron here can scatter to any value here. So, there are two possibilities one it is scattered from x to $-x$ so that is called g process this cation is called g process. And there is one possibility because there only one such value here. But if it is scattered perpendicular then there are four possibilities $+z, -z, +y, -y$ so this is called f process. So, this is basically D_{ij} is the intervalley deformation potential.

Then Z is a number of variable available, final values for s carrier to s scatter into and of course $\hbar\omega$ is the energy of optical phonon involved in the scattering process and ΔE_j is the energy potential energy difference between the bottom of valley j and bottom of i . So, let us say this is value j this is value i . So, what is the difference between their energies so that is ΔE_j . And then of course if you sum over all the S_k for S_k, k prime.

Then you get this expression where n is basically the phonon occupancy factor because this scattering is affected by the phonon it is due to the phonon. So, the if higher is the phonon consultation greater is the scattering so at the high temperature there will be more scattering basically. So, this is n and this if you see the phonon occupancy factor, they have different statistic not the Fermi Dirac statistics but this is called Bose Einstein statistic.

So, they use this kind of statistic. This you do not have to remember but understand that how this different scattering phenomena work out.

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OPTICAL PHONON SCATTERING



$$S(\mathbf{k}, \mathbf{k}') = \frac{\pi D_{ij}^2 Z_j}{\rho \omega_{ij} \Omega} \left[n(\omega_{ij}) + \frac{1}{2} \mp \frac{1}{2} \right] \delta(E_{\mathbf{k}'} - E_{\mathbf{k}} \mp \hbar \omega_{ij} + \Delta E_{ji}) \quad \text{In GaAs}$$

D_{ij} is the intervalley deformation potential

Z_j is the total number of available final valleys for the carrier to scatter into

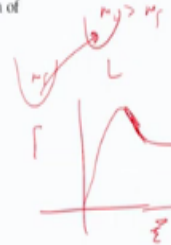
$\hbar \omega_{ij}$ is the energy of the intervalley optical phonons involved in the scattering process

ΔE_{ji} is the potential energy difference between the bottom of valley j and the bottom of valley i

$$v_d(E) = \frac{n_{\Gamma} \mu_{\Gamma} + n_L \mu_L}{n_{\Gamma} + n_L} \quad \epsilon$$

For negative differential mobility

$$\frac{dv_d(E)}{dE} < 0 \Rightarrow \frac{d\eta}{dE} > \frac{(\mu_{\Gamma}/(\mu_{\Gamma} - \mu_L)) - \eta}{E}$$



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Then of course in case of gallium arsenate there are valleys here. There is a gamma valley, there is a L valley and then there is a scattering here from gamma valley to L valley. And if you recall that the mass is actually more here let us, say m_L is more than m_{gamma} this is m_{gamma} . So, that is when these electron go to higher energy state their mobility actually reduces. So, we have this negative differential resistance region with the electric field or the applied voltage.

So, that is dragged here. So, the drift velocity is μ times E and the μ is basically the average of two values gamma valley and L valley. And if you take the derivative dv by dE it should be negative and then we can get the condition for negative differential mobility and that comes out to around that mobility in L should be less than mobility in gamma.

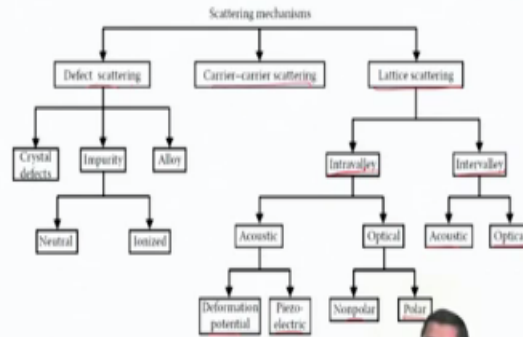
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VARIOUS SCATTERING MECHANISMS



- Phonon Scattering
 - Acoustic Phonon Scattering
 - Nonpolar Optical Phonon Scattering
 - Polar Optical Phonon Scattering
 - Piezoelectric Scattering
- Defect Scattering
 - Ionized Impurity Scattering
 - Neutral Impurity Scattering
 - Alloy Disorder Scattering
- Electron-Electron Interactions
- Electron-Plasmon Scattering
- Impact Ionization



SEMICONDUCTOR DEVICE MODELING AND SIMULATION

So, here is a summary of different scattering processes. So, there is a lattice scattering then of course within the same valley or they can be across the valley inter valley and intra valley. And then for both there are optical phonon and acoustic phonons and for intra valley there may be some polarity thing may be there. So, there are non-polar and polar and there is a different potential and the piezoelectric scattering are there.

And of course, there can be due to defect scattering so there can be neutral defect and ionized effect. And then there can be carrier-carrier scattering also because at a given position if you have lot of carriers this carrier will also scatter away.

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CONCLUSION



- Scattering mechanisms and mobility discussed

$$\frac{1}{\tau} = \frac{1}{\tau_1} + \frac{1}{\tau_2} + \frac{1}{\tau_3} + \dots$$
$$\mu = \frac{q}{m} \tau$$
$$\frac{1}{\mu} = \frac{1}{\mu_1} + \frac{1}{\mu_2} + \frac{1}{\mu_3} + \dots$$



SEMICONDUCTOR DEVICE MODELING AND SIMULATION

So, we have discussed different scattering mechanism and we have discussed the concept mobility that is arising from this scattering mechanism. So, in summary all this scattering mechanism combined together and all the S scattering rate actually combine. So, $1/\tau$ will be $1/\tau_1 + 1/\tau_2 + 1/\tau_3$ and so on and this we can do only if these have same energy dependence.

And if energy dependence is different then of course we have to be little careful and similar applies to mobility because mobility is E average of τ by m . So, this will be $1/\mu = 1/\mu_1 + 1/\mu_2$. So, in previous class we discussed this scattering that relaxation time approximation and then in this lecture we discuss different scattering mechanism leading to the different characteristic due to different mechanism and their different temperature dependence. Thank you very much.